

PATENT NUMBER and ISSUE DATE

APPL NUM	FILING DATE		SUBCLASS		EXAMINER
10099641	03/15/2002	438	75	2829	, , .
**APPLICANT	S: Cataba	y Wilbur;	Schinella Rich	ard;	
THIS APPLICA	G DATA VERIFIED ATION IS A DIV OF M. Jew. V	F 09/428 I	056 10/22/199 UM	9 PAT 8.	391,795
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Foreign priority cla 85 USC 119 condi		□ ye:	000		
	wiedged Examiners's i		ne		99-102/1D
ITLE : Low k o	fielectric compositi ial between metal	e layer for lines while	r integrated cir. e mitigation ute	cuit struc	ture which provides void-free low k
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NOTICE OF ALLOWANCE MAILED			CLAIMS ALLOWED							
		Assistant Examiner	Yotal Claims		Print Claim for 0.0					
ISSUE FEE		1		DRAWING						
Amount Due	Date Paid		Sheets Drug. Figs.Drug.		-	Print Fig.				
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TERMINAL		PREPARED FOR ISSUE	Application Examiner							
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